L Number	Hits	Search Text	DB	Time stamp
-	11103	("5595606").PN.	USPAT;	2003/02/24 14:58
			US-PGPUB	
	1228	with vacuum) and ("pvd" (physical with	USPAT; US-PGPUB	2003/02/24 10:34
_	174	<pre>vapor with deposition) sputter\$3)).CCLS.</pre>	USPAT; US-PGPUB	2003/02/24 10:59
_	65	vapor with deposition) sputter\$3) 118/\$.ccls. and ((ampoule ampule) and	USPAT;	2003/02/24 11:00
_	47	liquid) 5595606.URPN.	US-PGPUB USPAT	2003/02/24 12:37
_	0	("sandhu and (atomic with layer with deposition)").PN.	USPAT; US-PGPUB	2003/02/24 12:37 2003/02/24 14:59
_	0	("sandhu.in. and (atomic with layer with deposition)").PN.	USPAT; US-PGPUB	2003/02/24 14:59
	0	(("(inert with gas with curtain)") or ("and (atomic with layer with deposition)")).PN.	USPAT; US-PGPUB	2003/02/24 14:59
-	4	(inert with gas with curtain) and (atomic with layer with deposition)	USPAT; US-PGPUB	2003/02/24 15:10
_	4	(("4226208") or ("4341592") or ("5366555") or ("5382126")).PN.	USPAT; US-PGPUB	2003/02/24 15:10
_	0	("gattuso.in.").PN.	EPO; DERWENT	2003/02/24 15:11
_	48 163830	gattuso.in. gattuso.in. exhaust	USPAT; US-PGPUB	2003/02/24 15:11
_	41	gattuso.in. exhaust	USPAT; US-PGPUB EPO;	2003/02/24 15:11
_	1	gattuso.in. gattuso.in. and exhaust	DERWENT EPO;	2003/02/24 15:12
_	2	gattuso.in. and curtain and pressure	DERWENT EPO;	2003/02/24 15:12
_	32	(gas with curtain) with (isolat\$3	DERWENT USPAT;	2003/09/09 10:13
_	10	separat\$3 constrain\$3) with pressure (gas with curtain) with (isolat\$3 separat\$3 constrain\$3) with pressure	US-PGPUB EPO; JPO; DERWENT	2003/09/09 10:14
-	32	(gas with curtain) with (isolat\$3 separat\$3 constrain\$3) with pressure	USPAT; US-PGPUB	2003/09/09 10:14
-	1	("6319553").PN.	USPAT; US-PGPUB	2004/07/15 13:57
-	1	("5747113").PN.	USPAT; US-PGPUB	2004/07/15 13:57
_	23	(US-5595606-\$ or US-5076205-\$ or US-4226208-\$ or US-4836905-\$ or US-4465416-\$ or US-6098964-\$ or US-5431733-\$ or US-5968379-\$ or US-4747367-\$ or US-4080926-\$ or	USPAT; US-PGPUB; EPO; DERWENT	2004/07/15 14:16
-	3	US-5366555-\$ or US-5382126-\$ or US-4341592-\$ or US-3790404-\$ or US-5747113-\$ or US-6319553-\$).did. or (US-20030017267-\$ or US-20030033984-\$ or US-20010042523-\$ or US-20020046705-\$ or US-20020195056-\$).did. or (EP-60626-\$).did. or (US-4545136-\$).did. ((US-5595606-\$ or US-5076205-\$ or US-4226208-\$ or US-4836905-\$ or US-4465416-\$ or US-6098964-\$ or	USPAT; US-PGPUB	2004/07/15 14:17
		US-5431733-\$ or US-5968379-\$ or US-4747367-\$ or US-4080926-\$ or US-5366555-\$ or US-5382126-\$ or US-4341592-\$ or US-3790404-\$ or US-5747113-\$ or US-6319553-\$).did. or (US-20030017267-\$ or US-20030033984-\$ or US-20010042523-\$ or US-20020046705-\$ or US-20020195056-\$).did. or (EP-60626-\$).did. or (US-4545136-\$).did.) and (separate with (heat\$3 temperatue\$3))		

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(separate with (heats3 temperatuse\$3); (187719.ccls. 156/345.32.ccls. 414/939.ccls. 156/345.32.ccls. 414/939.ccls. 2004/07/15 15:22 2004/07/15 15:22 (187719.ccls. 156/345.32.ccls.) and (separate with (heats3 temperature\$3)); (118/719.ccls. 156/345.32.ccls.) and (individual with (heats3 temperature\$3)); (118/719.ccls. 156/345.31.ccls. 156/345.32.ccls. 414/939.ccls. 204/298.25.ccls. 204/298.25.ccls.) and (individual with (heats3 temperature\$3)); not (118/719.ccls. 156/345.31.ccls. 156/345.32.ccls. 414/939.ccls. 204/298.25.ccls. 204/298.25.ccls.) and (separate with (heats3 temperature\$3)); not (118/719.ccls. 156/345.31.ccls. 156/345.32.ccls. 414/939.ccls. 204/298.25.ccls. 204/298.25.ccls.) and (separate with (heats3 temperature\$3))); not (118/719.ccls. 156/345.31.ccls. 156/345.32.ccls. 414/939.ccls. 204/298.25.ccls. 204/298.25.ccls.) and (susceptor platen plate holder) with (heaters)); (118/719.ccls. 156/345.31.ccls. 156/345.32.ccls. 414/939.ccls. 204/298.25.ccls. 204/298.25.ccls.) and (susceptor platen plate holder) with (heaters) with (individuals4 separats4)); ("ald" "atomic layer epitaxy" "atomic layer deposition") and ((heaters) with (individuals4 separats4)); ("ald" "atomic layer epitaxy" "atomic layer deposition") and (heaters) with (dastinct)); ("ald" "atomic layer epitaxy" "atomic layer deposition") and (heaters) with (dastinct)); ("ald" "atomic layer epitaxy" "atomic layer deposition") and (heaters) with (dastinct)); ("ald" "atomic layer epitaxy" "atomic layer deposition") and (heaters) with (dastinct)); ("ald" "atomic layer epitaxy" "atomic layer deposition") and (heaters) with (dastinct)); ("ald" "atomic layer epitaxy" "atomic layer deposition") and (heaters) with (dastinct)); ("ald" "atomic layer epitaxy" "atomic layer deposition") and (heaters) with (dastinct)); ("ald" "atomic layer epitaxy" "atomic layer deposition") and (heaters) with (dastinct)); ("alger deposition") and (heaters) with (dastinct)); ("alger deposition") and (heaters) with (dastinct)); ("alger "atomic layer deposition") and (heaters			156/345.32.ccls. 414/939.ccls.	US-PGPUB	
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(individual with (heat\$3 temperature\$3))) not ((118/719.ccls. 156/345.31.ccls. 156/345.32.ccls. 414/939.ccls.) and (separate with (heat\$3 temperature\$3))) ("6042652").PN. 1 ("6042652").PN. 249 (118/719.ccls. 156/345.31.ccls. 156/345.32.ccls. 414/939.ccls. 204/298.25.ccls. 204/298.35.ccls.) and ((susceptor platen plate holder) with (heaters)) (118/719.ccls. 156/345.31.ccls. 156/345.32.ccls. 414/939.ccls. 204/298.25.ccls. 204/298.35.ccls.) and ((susceptor platen plate holder) with (heaters)) (118/719.ccls. 156/345.31.ccls. 156/345.32.ccls. 414/939.ccls. 204/298.25.ccls. 204/298.35.ccls.) uspat; USPAT; US-PGPUB ((susceptor platen plate holder) with (heaters) with rotat\$5) ("ald" "atomic layer epitaxy" "atomic layer deposition") and ((heaters) with (individual\$4 separat\$4)) ("ald" "atomic layer epitaxy" "atomic layer deposition") and ((heaters) with (each)) ("ald" "atomic layer epitaxy" "atomic layer deposition") and ((heaters) with (each)) ("ald" "atomic layer epitaxy" "atomic layer deposition") and ((heaters) with (distinct)) ("ald" "atomic layer epitaxy" "atomic layer deposition") and ((heaters) with (findividual\$4 separat\$4)) ("ald" "atomic layer epitaxy" "atomic layer deposition") and ((heaters) with (each)) ("ald" "atomic layer epitaxy" "atomic layer deposition") and ((heaters) with (distinct)) ("ald" "atomic layer epitaxy" "atomic layer deposition") and ((heaters) with (distinct)) ("ald" "atomic layer epitaxy" "atomic layer deposition") and ((heaters) with (distinct)) ("ald" "atomic layer epitaxy" "atomic layer deposition") and ((heaters) with (distinct)) ("ald" "atomic layer epitaxy" "atomic layer deposition") and ((heaters) with (distinct)) ("ald" "atomic layer epitaxy" "atomic layer deposition") and ((heaters) with (distinct)) ("ald" "atomic layer epitaxy" "atomic layer deposition") and ((heaters) with (distinct)) ("BAT; US-PGPUB ("SPAT; US-PGPUB ("SPAT; US-PGPUB ("SPAT; US-PGPUB ("SPAT; US-PGPUB ("SPAT; US-PGPUB ("SPAT; US-PGPUB ("SOU4/07/16 13:31)			156/345.32.ccls. 414/939.ccls.	US-PGPUB	
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196/345.32.ccls. 414/939.ccls. US-PGPUB 2004/07/15 17:43 2004/298.25.ccls. 204/298.35.ccls.) and ((susceptor platen plate holder) with (heaters)) (118/719.ccls. 156/345.31.ccls. 204/298.25.ccls. 414/939.ccls. 204/298.25.ccls. 204/298.35.ccls.) and ((susceptor platen plate holder) with (heaters) with rotat\$5)	_	249		USPAT;	2004/07/15 16:27
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	-	1	("5935334").PN.		2004/07/16 12:21
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